

## **OSIRIS Multiobject spectroscopy mask design process**

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### **Abstract**

OSIRIS instrument at 10.4 m GTC offers Multi-Object spectroscopic mode since March 1<sup>st</sup> 2014. In this poster we describe the detailed process for designing a MOS mask for OSIRIS by using the Mask Designer Tool, and give some numbers on the accuracy in the mask manufacture achievable at the telescope for its scientific use.